

**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

**Patent Application**

Applicant(s): Babich et al.  
Docket No.: YOR920030174US1  
Serial No : 10/634,667  
Filed: August 5, 2003  
Group: 1752  
Examiner: A C. Walke

Title: Lithographic Antireflective Hardmask Compositions and Uses Thereof

---

AMENDMENT AND RESPONSE TO OFFICE ACTION

Mail Stop Amendment  
Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Sir:

In response to the outstanding Office Action, dated July 26, 2006, Applicants submit the following amendments and remarks.